

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/553,573
Applicants: Christian DUSSARRAT et al.
Filed Internationally: April 8, 2004
US National: October 17, 2005
Title: METHODS FOR PRODUCING SILICON NITRIDE FILMS
BY VAPOR-PHASE GROWTH
TC/A.U.: 1715
Examiner: Elizabeth A. Burkhart
Docket No.: Serie 6070
Customer No.: 40582

AMENDMENT AFTER FINAL

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

In response to the Final Office Action mailed April 4, 2011, having a shortened statutory period for response set to expire on July 4, 2011, Applicants respectfully request reconsideration of the present application in view of the following amendments and/or remarks:

Amendments to the Claims begin on page 2 of this paper.

Remarks begin on page 4 of this paper.